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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Applicant: GUI et al.

Appln. No.: 10/043,271

Filing Date: January 14, 2002

Date: May 31, 2002   Page 1 of 1   Examiner: UNKNOWN   Group Art Unit: 2851

U.S. PATENT DOCUMENTS

Examiner's Initials*		Document Number	Date MM/YYYY	Name (Family Name of First Inventor)	Class	Sub Class	Filing Date (if appropriate)
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P/L	BR	4,952,060	08/1990	INA et al.			
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	KR						
	LR						
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	NR						

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P/L	OR	0 756 207 A3	01/1997	EUROPE	TANAKA et al.					
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	QR									
	RR									
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OTHER (Including in this order Author, Title, Periodical Name, Date, Pertinent Pages, etc.)

P/L	TR	Patent Abstract of Japan, JP11340120, published December 1999
P/L	UR	Patent Abstract of Japan, JP05144702, published June 1993
P/L	VR	Patent Abstract of Japan, JP3246923, published November 1991
P/L	WR	Patent Abstract of Japan, JP1164032, published June 1989
P/L	XR	Katagiri et al., "Novel alignment technique for 0.1-μm lithography using the wafer rear surface and canceling tilt effect," *Optical Engineering* 32(10):2344-2349 (1993)
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	AAR	

Examiner	Date Considered:

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.
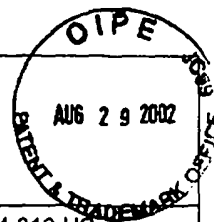
PAT-1449 12/98

FORM PTO-1449 (modified) To: U.S. Department of Commerce (PW FORM PAT-1449) Patent and Trademark Office	Atty. Dkt. No.	M#	
	290598	P-0224.010.US	

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Applicant: GUI et al.

Appln. No.: 10/043,271

Filing Date: January 14, 2002

Date: August 29, 2002   Page 1 of 1   Examiner: UNKNOWN   Group Art Unit: 2851

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